

HeatWatch:

Improving 3D NAND Flash Memory Device Reliability by Exploiting Self-Recovery and Temperature Awareness

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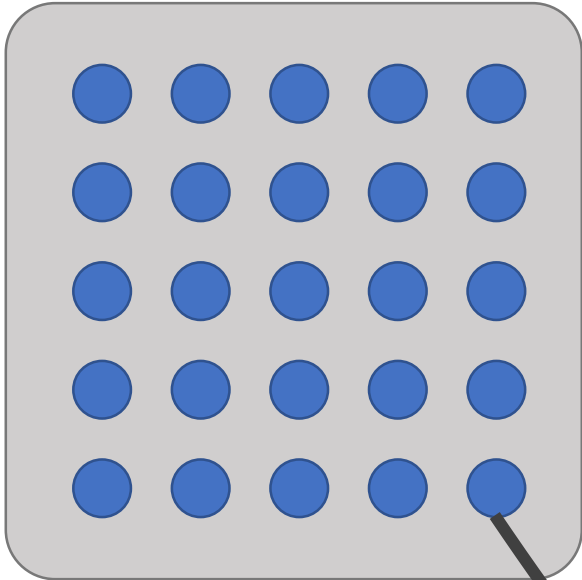


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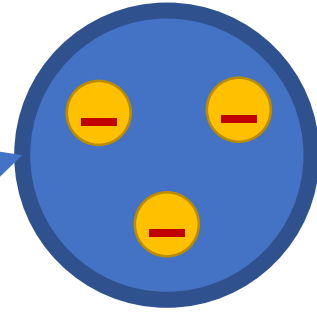
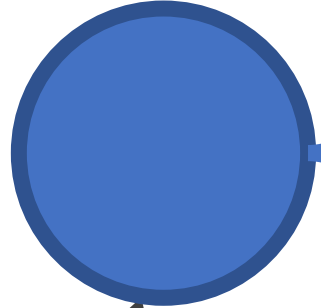
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NAND Flash Memory



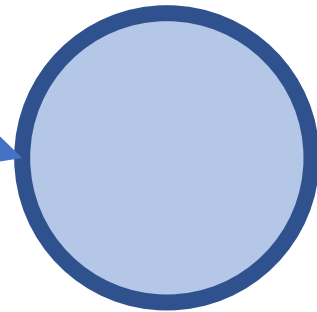
Flash Cell



Higher Voltage State

Data Value = **0**

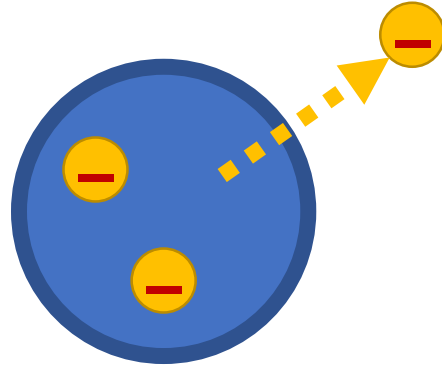
Read Reference Voltage



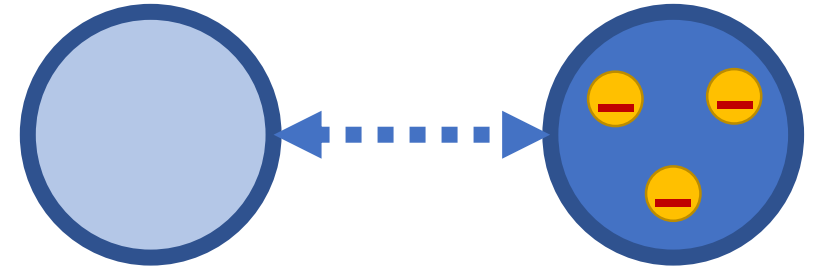
Lower Voltage State

Data Value = **1**

Flash Reliability and Lifetime Factor



1. Retention Loss Speed



2. Program variation

Physical
Phenomenon

Self-Recovery
Effect

Temperature
Effect

Our Contributions

3D NAND Flash Characterization

First experimental characterization

Real 3D NAND chips

Self-recovery slows down
retention loss by:

40%

High temperature increases
program variation by:

21%

URT Model

A new comprehensive model that
unifies 4 most significant effects
that affect flash reliability

Prediction error rate:

4.9%

HeatWatch

A new mechanism that
adapts read reference voltage to
access pattern and temperature

Improves flash lifetime by:

3.85x

Memory/Storage
overhead:

<1.6MB

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Session 6A – Tuesday 11:20 AM

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Paper download link:
http://yixinluo.com/index_files/heatwatch_hpca18.pdf